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# Diffraction limited focal spots for off-thermal equilibrium 100-TW Nd:Glass laser chain using a dielectric coated deformable mirror

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Abstract: We demonstrate the use of a dielectric-coated deformable mirror to correct LULI 100-TW Nd:Glass facility spatial aberrations. Almost diffraction limited foci have been obtained even when the laser chain amplifiers were highly off thermal equilibrium.

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High power CPA laser chains, such as the LULI (Laboratoire pour l'Utilisation des Lasers Intenses) 100-TW laser facility, require high focusing quality in order to reach up to  $10^{21}$  W.cm<sup>-2</sup> peak intensity. Managing wave front aberrations is crucial to concentrate as much energy in the smallest spot possible. Moreover the focal spot should be reproducible so that physics experiments could also be reproducible. For any of the high energy CPA facilities in the world, these requirements cannot be fulfilled for full power shots. First, thermal effects induced by optical pumping at high energy as well as the aberrations brought by the optical components, including the large aperture gratings, deform the pulse wave front. Second, as soon as one desires to shoot at a high repetition rate, cumulative thermal effects will increase temperature and strain in amplifiers materials at each shot. In this case, shots are not reproducible whereas the focusing quality decrease from one shot to another.

At LULI, we tried two devices in order to correct full power shots: an electro-optical valve [1] and a deformable mirror (DM) [2]. This paper deals with the second solution. Since fluence at the output of the laser chain is 600 mJ.cm<sup>-2</sup> at 750 ps pulse duration (30 J in a 80 mm aperture), we used a dielectric coated DM in order to prevent any laser-induced damage. In order to get the highest focusing quality, the DM should be placed as close as possible to the focusing optics. In a CPA laser chain, this means between the compressor last grating and the focusing parabola, i.e. in vacuum. To avoid risks of electrical breakdown in vacuum due to the high voltages applied on the electrodes, the DM was alternatively placed at 0° incidence as a replacement of the mirror enabling double-pass in the final slab-amplifier (see Fig.1).

We measured the wave front with a three wave shearing interferometer (ATWLSI) [3] at two different locations: at the end of the amplifying chain and after compression. Both were used as input for our adaptive optic loop, enabling us to compare their potential to improve the focal spot quality in the target chamber. The first interferometer imaged the deformable mirror plane, whereas the second one imaged a plane within the compressor. Though the second one did not image the deformable mirror plane, we still obtained very stable convergences. After compression, the beam, attenuated to avoid non-linear effects in glass, was focused by a long focal (f=1200 mm) lens

We compared non-corrected and corrected shots (see Fig. 2) for a sequence of 30 J shots every 20 minutes. In the first case, aberrations grow from one shot to another due to cumulative heat in the slab-amplifier. In the second case, we converged to a flat phase just before each shot and froze the voltages on the mirror during the shot itself. This resulted in reproducible diffraction-limited focal spots for any full power shot in a series (see Fig. 3). We estimated an increase of a factor 4 on the peak intensity from a non-corrected shot to a corrected shot. This means

that with our f/15 focusing lens we could obtain intensities above  $10^{20}$  W.cm<sup>-2</sup>. Future physics experiments will use this device with a f/3 off-axis parabola, allowing intensities above  $10^{21}$  W.cm<sup>-2</sup>.

Concepts developed for this project will be applied to the LULI Petawatt project currently under construction. References

- [1] B. Wattellier, J. C. Chanteloup, J. Fuchs, et al., CLEO 2001 Technical Digest, 70 (2001).
- [2] A. V. Kudryashov and V. I. Shmalhausen, Optical Engineering 30, 2663 (1996).
- [3] J. C. Chanteloup, F. Druon, M. Nantel, et al., Optics Letters 23, 621 (1998).

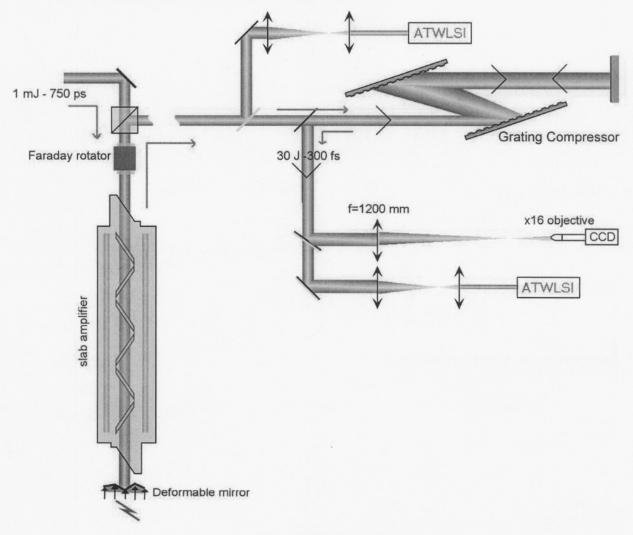


Fig. 1 – Experimental set-up

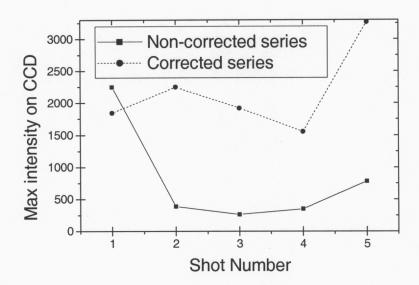


Fig. 2 – Evolution of maximum intensity on the CCD recording the far-field patterns vs. shot number. This value is proportional to the maximum intensity in the focal plane. An average gain of 4 on peak intensity is observed from non-corrected shots to corrected shots.

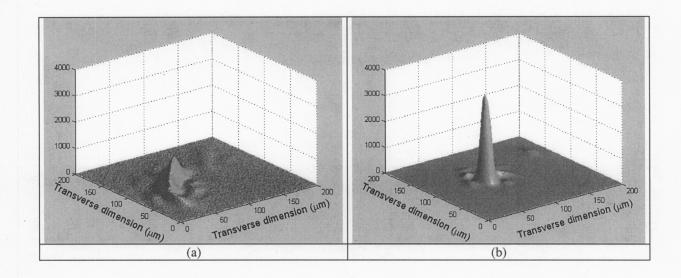


Fig. 3 – Examples of far-field patterns: (a) non-corrected shot #5 - (b) corrected shot #5